

Atlanta Sewing Center

Advanced Applique and Embroidery Supply List

Instructor: Iris Lee

Applique using the embroidery machine and Bernina Version 6 Software is fun and so much faster than hand applique. Our beginner class, held previously, covered closed-object and open-object, but this class will review these techniques and include partial applique and combining applique with normal embroidery. The class will be broken into two sections: the first section will be from 10:30am-12:30pm and we will work with the computer. You can bring your own computer or simply audit the class. After your lunch break from 12:30pm to 1:30pm, we will stitch out the design. I will bring enough fabric for the applique parts of the design. You will need to bring the background fabric. I will also bring rotary cutters in case we need them. Please bring the following supplies.

- Sewing machine and embroidery unit
- Largest hoop you have for your embroidery machine
- Two or three pieces of solid colored fabric that is large enough to fit in hoop
- Medium weight stabilizer to fit fabric and hoop, tear away or cutaway.
- Iron on stabilizer or spray adhesive
- Pins, new needle
- Small trimming scissors, & fabric scissors
- Various colors of embroidery thread
- Thread for bobbin to match solid fabric
- Embroidery foot #26 or whichever # you use for your machine.

A 10% discount will be given for any items purchased at the Atlanta Sewing Center for this class.

Class Policies: **Please wait to purchase your supplies until your class has been confirmed.** Confirmation is made one week prior to the beginning of class. Your name should be marked on all tools and supplies. Classes begin promptly at the time specified. Plan to arrive so that you will be set up and ready to begin on time. Thank you for your cooperation with our class policies.

Cancellation Policy: Cancellations must be made one week prior to the first class meeting. We cannot offer refunds or credit for late cancellations. Thank you for your cooperation with our Cancellation Policy. December 2009